Special Issue

Silicon Photonics: Industrial Applied Materials and Technologies

Message from the Guest Editor

Silicon photonics is among the top ten emerging technologies in microelectronics and is forecast by the MIT Communications Technology Roadmap to develop into a \$20B annual market. Silicon photonics represents a technology which on the one hand builds on the welldeveloped methods of CMOS-compatible fabrication and yet, on the other, is potentially disruptive in its promise to revolutionize high-performance computing and sensing. Practical implementation in commercial devices will require low loss waveguides, polarization handling, tunability, and hitless switching. Fundamental and applied advances have been made in areas such as silicon waveguides, optical sources, optical modulators, photodetectors, and integration. These advances rest upon myriad solutions to problems such as growth, etching and bonding of a variety of materials including not only Si and SiO2 but also III-V semiconductors, lithium niobate, transparent conductive oxides or even graphene.

Guest Editor

Prof. Dr. Kurt W. Kolasinski

Department of Chemistry, West Chester University of Pennsylvania, West Chester, PA 19383, USA

Deadline for manuscript submissions

closed (15 December 2022)



Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



mdpi.com/si/127086

Applied Sciences Editorial Office MDPI, Grosspeteranlage 5 4052 Basel, Switzerland Tel: +41 61 683 77 34 applsci@mdpi.com

mdpi.com/journal/applsci





Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal *Applied Sciences* has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

Prof. Dr. Giulio Nicola Cerullo

Dipartimento di Fisica, Politecnico di Milano, Piazza L. da Vinci 32, 20133 Milano, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, CAPlus / SciFinder, and other databases.

Journal Rank:

JCR - Q2 (Engineering, Multidisciplinary) / CiteScore - Q1 (General Engineering)

